ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Flectronic Version v18

Stylesheet Version v18.0

	Title of
- 1	nvention

LOW-K INTERLEVEL DIELECTRIC LAYER (ILD) AND METHOD

Application Number :

Confirmation Number:

First Named Applicant:
Attorney Docket Number:

Matthew Angyal

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Art Unit: Examiner:

Search string:

(6528432 or 6436808 or 6483173).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6528432	2003-03-04	Ngo, et al.			
	2	6436808	2002-08-20	Ngo, et al.			
	3	6483173	2002-11-19	Li, et al.			

Signature

Examiner Name	Date